

ABSTRACT OF THE DISCLOSURE (FIG. 2)

"METHOD AND APPARATUS FOR COATING A FILM ON AN
OBJECT BEING PROCESSED"

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Disclosed herein is a method and an apparatus for
applying a coating liquid to an object from a liquid-
applying member at a first prescribed position, thereby
forming a film on the object. Before the coating
10 liquid at the first position, the coating liquid is
applied at a second predetermined position. An
impurity-detecting device detects the impurities
contained in the coating liquid applied at the second
position. A particle-counting device is provided, and
15 a switching device is provided on a liquid-supplying
pipe extending from a source of the coating liquid to
the liquid-applying member. The switching device
switches the supply of the coating liquid between the
liquid-applying member and the impurity-detecting
20 device. The impurities in the coating liquid can
thereby monitored.